

TECHNICAL CIRCUIT

No. GO-I/Tech.Cir./2642

Office of the,
Superintending Engineer (Gates)
Central Designs Organisation
Pindori Road, Nasik-422 004.
Dated :- 29 October, 1980.

Sub :- Location of sill beam for S.O. and
S.O. leaves.

It is observed that no uniform practice is followed to locate the sill beam for the S.O. and S.O. leaves. Where-as some drawings show the sill beam at the centre of the skin plate of the gate leaf, other drawings show the sill beam at the centre of the bottom seal of the gate leaf. It is necessary to provide the sill beam at the centre line of the bottom seal, so that the bottom seal gets compressed and positive seal is obtained. This practice should be followed hence-forward.

O. G. approved by S. E. (S.)

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